

External_Type	Material_Group	Substances	CAS_Number	Mass	Mass_Percentage_in_Leaf	Massmg
Lead Frame	Copper alloy	Phosphorous (P)	7723-14-0	0.03746	0.1	0.401
	Copper alloy	Nickel (Ni) - cas no. 7440-02-0	7440-02-0	0.01124	0.03	0.1203
	Copper alloy	Iron (Fe)	7439-89-6	0.03746	0.1	0.401
	Copper alloy	Copper (Cu)	7440-50-8	37.377	99.77	400.0777
Subtotal				37.46316	100	401
Mould Compound	Polymer	Phenol Formaldehyde resin (generic)	9003-35-4	2.83861	4.8	30.384
	Polymer	Epichlorohydrin/Diethyleneglycol Epoxy resin (generic)	25928-94-3	5.91376	10.0	63.3
	Filler	Silica fused	60676-86-0	50.26697	85.0	538.05
	Carbon Black	Carbon black	1333-86-4	0.11828	0.2	1.266
Subtotal				59.13762	100	633
Post-plating	Pure metal	Tin (Sn)	7440-31-5	2.33561	100.0	25
		Subtotal				2.33561
Die Attach	Lead alloy	Tin (Sn)	7440-31-5	0.00361	2.0	0.0386
		Silver (Ag)	7440-22-4	0.00451	2.5	0.04825
		Lead (Pb)	7439-92-1	0.1722	95.5	1.84315
Subtotal				0.18032	100	1.93
Die		Lead Dioxide (PbO2)	1309-60-0	0.00395	0.9	0.0423
	Doped silicon	Silicon (Si)	7440-21-3	0.43514	99.1	4.6577
Subtotal				0.43909	100	4.7
Wire	Pure metal	Aluminium (Al)	7429-90-5	0.44421	100.0	4.7548
Total				100.00001	100	1070.3848

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